

**ArF Immersion Scanner** 

# NSR-5620D

**ENABLING THE NEXT GENERATION** 



## ArF immersion scanner with new Streamlign platform enables rapid production ramps required for 32 nm, and provides extendibility to 22 nm applications.

The NSR-S620D incorporates three newly developed technologies — Bird's Eye Control, Stream Alignment, and the Modular<sup>2</sup> Structure — to make it the optimal immersion scanner for double patterning. The NSR-S620D design builds upon the unique Tandem Stage and local fill technologies employed in the Nikon NSR-S610C, the world's first ArF immersion scanner for 45 nm node volume production. NSR-S620D

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Resolution	≦ 38 nm	
NA	1.35	
Exposure light source	ArF excimer laser (193 nm wavelength)	
Reduction ratio	1:4	
Maximum exposure field	26 mm × 33 mm	
Overlay	≦ 3 nm	
Throughput	≥ 180 wafers/hour (300 mm wafer, 125 shots)	

#### Main Characteristics of the Streamlign Platform

#### Bird's Eve Control **Enabling superior yield**

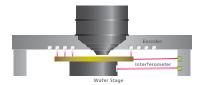
- Hybrid encoder/interferometer system delivers optimal stage performance.
- Dramatically improves accuracy and stability.
- Provides superior focus control.
- Targeting 2 nm overlay capabilities.

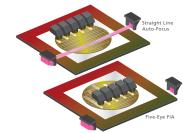
#### Stream Alignment **Enabling optimal affordability**

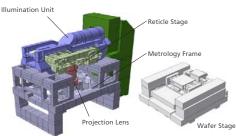
- Straight Line Auto-Focus generates a dense map of the wafer surface to enhance focus control (using wider AF beam span).
- Enables increased alignment sites with minimal productivity impact using Five-Eye FIA.
- Greatly reduces wafer overhead time.
- Targeting throughput up to 200 wph.

### Modular<sup>2</sup> Structure **Enabling rapid production ramps**

- Simplifies maintenance by the modular design.
- Provides optimal uptime with modular design and individual components replacement.
- Extendible platform enables multigenerational use.











WARNING

TO ENSURE CORRECT USAGE, READ MANUALS CAREFULLY BEFORE USING YOUR EQUIPMENT.

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